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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/588,292	06/07/2000	Naoya Eguchi	P00,0723	9151

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EXAMINER

CARTER, AARON W

ART UNIT	PAPER NUMBER
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2625

DATE MAILED: 04/08/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

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Office Action Summary

Application No.

09/588,292

Applicant(s)

EGUCHI, NAOYA

Examiner

Aaron W Carter

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 26 March 2002.
- 2a) ☐ This action is FINAL. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-10 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-10 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 07 June 2000 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on _____ is: a) ☐ approved b) ☐ disapproved by the Examiner.
If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

- 13) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
a) ☒ All b) ☐ Some * c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
* See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

- 1) ☒ Notice of References Cited (PTO-892) 4) ☐ Interview Summary (PTO-413) Paper No(s). _____
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948) 5) ☐ Notice of Informal Patent Application (PTO-152)
- 3) ☒ Information Disclosure Statement(s) (PTO-1449) Paper No(s) 7. 6) ☐ Other: _____

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 1-4,6,7 and 10 rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent 5,479,252 to Worster et al. (“Worster”) (previously of record).

As to claim 1, Worster discloses an inspection equipment comprising:

means for supporting a specimen and moving it to a predetermined position of inspection (column 4 line 66 – column 5 line 3 and lines 13-20);

means for projecting an ultraviolet light onto the specimen supported on the specimen supporting means (column 6, lines 4-11);

an ultraviolet imaging means for detecting a reflected or transmitted light from the specimen illuminated by the ultraviolet light projecting means to pick up an image of the specimen (column 6, lines 12-14); and

means for processing the image picked up by the ultraviolet light projecting means to pick up an image of the specimen (column 8, lines 36-39); and

the image picked up by the ultraviolet imaging means being processed and analyzed by the image processing means to inspect the specimen (column 8, lines 38-42).

As to claim 2, Worster discloses the equipment as set forth in claim 1, further comprising:

means for projecting a visible light to the specimen supported on the specimen supporting means (column 9, lines 61-63); and

a visible light imaging means for detecting a reflected or transmitted light from the specimen illuminated by the visible light projecting means to pick up an image of the specimen (column 10, lines 1-4);

the image picked up by the visible light imaging means being processed and analyzed by the image processing means to inspect the specimen with a low resolution (column 10, lines 4-12, wherein white light corresponds to visible light and it is inherent that inspection of the specimen is done at a lower resolution compared to the inspection with the ultraviolet laser image which inspects the specimen with a high resolution (column 6, lines 12-14)); and

the image picked up by the ultraviolet imaging means being processed and analyzed by the image processing means to inspect the specimen with a high resolution (column 6, lines 12-14).

As to claim 3, Worster discloses the equipment as set forth in claim 2, wherein the image picked up by the visible light imaging means is processed and analyzed by the image processing means to inspect the low frequency component, and image picked up by the ultraviolet imaging

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means is processed and analyzed by the image processing means to inspect the high frequency component (column 4, lines 3-5, wherein the ultraviolet light contains shorter wavelengths that produce a higher resolution image and thus used to inspect higher frequency components. The same holds true for the white light image, it is inherent that the white light contains longer wavelengths than the ultraviolet laser and that produce a lower resolution image and thus used for inspecting lower frequency components), thus dividing the band of a space frequency to be inspected.

As to claim 4, Worster discloses the equipment as set forth in claim 2, wherein;

The visible light imaging means comprises a lamp as a light source to project an incoherent light from the light source to the specimen (Fig. 3A, "White Light Lamp"); and

The ultraviolet imaging means comprises a laser as a light source to project a coherent light from the laser to the specimen (column 4, lines 3-5).

As to claim 6, Worster discloses the equipment as set forth in claim 1, further comprising:

a specimen placing mechanism for taking out the specimen having been carried in a predetermined container ("cassette"), from the container and placing it on the specimen supporting means ("vacuum chuck"), (column 5, lines 13-20); and

a dedusting clean unit to keep clean the internal environment (column 5, lines 5-7 and lines 21-24);

at least the specimen supporting means and specimen placing mechanism being provided inside the clean unit (column 5, lines 5-7 and lines 21-24).

As to claim 7, Worster discloses the equipment as set forth in claim 1, wherein the ultraviolet imaging means comprises an ultraviolet laser source as a light source to project an ultraviolet laser from the light source to the specimen (column 4, lines 3-5).

As to claim 10, Worster discloses the equipment as set forth in claim 1, wherein the specimen is a semiconductor wafer having a predetermined device pattern formed therein (column 3, lines 19-30 and column 5, lines 8-11).

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. Claim 5 is rejected under 35 U.S.C. 103(a) as being unpatentable over Worster as applied to claim 1 above, and further in view of U.S. Patent 5,619,429 to Aloni et al. ("Aloni")(previously of record).

As to claim 5, Worster discloses the equipment of claim 1, but neglects to explicitly disclose that the images of different areas of the specimen are picked up by the ultraviolet

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imaging means and the images are compared with each other by the image processing means to inspect the specimen. However Aloni teaches that as an alternative to using a database for providing a reference in a comparison based inspection, an area of the die may be used as a reference to inspect other areas of the same die (column 10, lines 42-47). Therefore it would have been obvious to one of ordinary skill in the art combine the invention of Worster and Aloni. This would eliminate the requirement for a database to store reference images of the semiconductors.

5. Claims 8 and 9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Worster as applied to claim 7 above, and further in view of an article entitled "All-Solid-State Tunable Ultraviolet Ce Activated Fluoride Laser Systems Directly Pumped by the Fourth and Fifth Harmonic of Nd: YAG Lasers" by Liu et al. ("Liu").

As to claim 8, Worster discloses the equipment as set forth in claim 7, wherein the ultraviolet laser source emits an ultraviolet laser having a shorter wavelengths than the optional multiline visible light laser (column 4, lines 1-7). It is known in the art that visible light consists of wavelengths between 400 and 700 nm, therefore Worster is indicating that his ultraviolet laser has wavelengths of less than 400 nm, however Worster does not explicitly disclose that the ultraviolet laser has a wavelength of less than 355 nm. However, Liu teaches us that it is typical of an ultraviolet laser to have wavelengths in this range, listing several different types of ultraviolet laser, in figure 2, with wavelengths that fall into the range of 220 to 340 nm. Therefore it is obvious to one of ordinary skill in the art to say that the ultraviolet laser consists

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of wavelengths less than 355 nm, since it is known in the art that this is the nature of an ultraviolet laser.

As to claim 9, Worster discloses the equipment as set forth in claim 7, but neglects to explicitly disclose that the ultraviolet laser is a solid laser. However, it is known in the art that ultraviolet lasers can be solid-state-laser, see Liu, page 343, paragraph 1, lines 1-2. Therefore it would have been obvious to one of ordinary skill in the art say that the ultraviolet laser source is a solid laser since it is known in the art that an ultraviolet laser can be solid-state lasers.

Conclusion

6. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

U.S. Patent 5,774,222 to Maeda et al. discloses inspection with the use of an ultraviolet laser.

U.S. Patent 6,388,744 to Kubota et al. discloses a similar invention by the same inventor.

U.S. Patent 5,912,735 to Xu discloses the use of both an ultraviolet laser and white light in an imaging system.

U.S. Patent 5,638,206 to Sumiya et al. discloses an inspection device that uses an ultraviolet laser.

Contact Information

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7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Aaron W. Carter whose telephone number is 703.306.4060. The examiner can normally be reached by telephone between 8am - 4:30pm (Mon. - Fri.).


If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bhavesh Mehta can be reached on 703.308.5246. The fax phone number for the organization where the application or proceeding is assigned is 703.872.9314 for regular communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703.306.0377.

Aaron W. Carter
Examiner
Art Unit 2625

awc

April 2, 2003


BHAVESH M. MEHTA
SUPERVISORY PATENT EXAMINER
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